

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention	FET GATE STRUCTURE WITH METAL GATE ELECTRODE AND SILICIDE CONTACT																																																																																																																						
<div>Application Number :</div> <div>Confirmation Number:</div> <div>First Named Applicant: Victor Ku</div> <div>Attorney Docket Number: FIS920030124</div> <div>Art Unit:</div> <div>Examiner:</div> <div>Search string: (6376888 or 6373111 or 5619057 or 6501131 or 6355531 or 4745079 or 20030119292 or 20020179975 or 20020086504 or 20020123189 or 20030011037 or 20030075766).pn</div>																																																																																																																							
<div>US Patent Documents</div> <div>Note: Applicant is not required to submit a paper copy of cited US Patent Documents</div> <table><tr><td>init</td><td>Cite.No.</td><td>Patent No.</td><td>Date</td><td>Patentee</td><td>Kind</td><td>Class</td><td>Subclass</td></tr><tr><td></td><td>1</td><td>6376888</td><td>2002-04-23</td><td>Tsunashima et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>2</td><td>6373111</td><td>2002-04-16</td><td>Zheng et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>3</td><td>5619057</td><td>1997-04-08</td><td>Komatsu</td><td></td><td></td><td></td></tr><tr><td></td><td>4</td><td>6501131</td><td>2002-12-31</td><td>Divakaruni et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>5</td><td>6355531</td><td>2002-03-12</td><td>Mandelman et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>6</td><td>4745079</td><td>1988-05-17</td><td>Pfiester</td><td></td><td></td><td></td></tr></table> <div>US Published Applications</div> <div>Note: Applicant is not required to submit a paper copy of cited US Published Applications</div> <table><tr><td>init</td><td>Cite.No.</td><td>Pub. No.</td><td>Date</td><td>Applicant</td><td>Kind</td><td>Class</td><td>Subclass</td></tr><tr><td></td><td>1</td><td>20030119292</td><td>2003-06-26</td><td>Lee et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>2</td><td>20020179975</td><td>2002-12-05</td><td>Wakabayashi et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>3</td><td>20020086504</td><td>2002-07-04</td><td>Park et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>4</td><td>20020123189</td><td>2002-09-05</td><td>Cha et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>5</td><td>20030011037</td><td>2003-01-16</td><td>Chau et al.</td><td></td><td></td><td></td></tr><tr><td></td><td>6</td><td>20030075766</td><td>2003-04-24</td><td>Lin et al.</td><td></td><td></td><td></td></tr></table>								init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass		1	6376888	2002-04-23	Tsunashima et al.					2	6373111	2002-04-16	Zheng et al.					3	5619057	1997-04-08	Komatsu					4	6501131	2002-12-31	Divakaruni et al.					5	6355531	2002-03-12	Mandelman et al.					6	4745079	1988-05-17	Pfiester				init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass		1	20030119292	2003-06-26	Lee et al.					2	20020179975	2002-12-05	Wakabayashi et al.					3	20020086504	2002-07-04	Park et al.					4	20020123189	2002-09-05	Cha et al.					5	20030011037	2003-01-16	Chau et al.					6	20030075766	2003-04-24	Lin et al.			
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Examiner Name	Date